



RUHR-UNIVERSITÄT BOCHUM

EM PIC modeling of CCP discharges

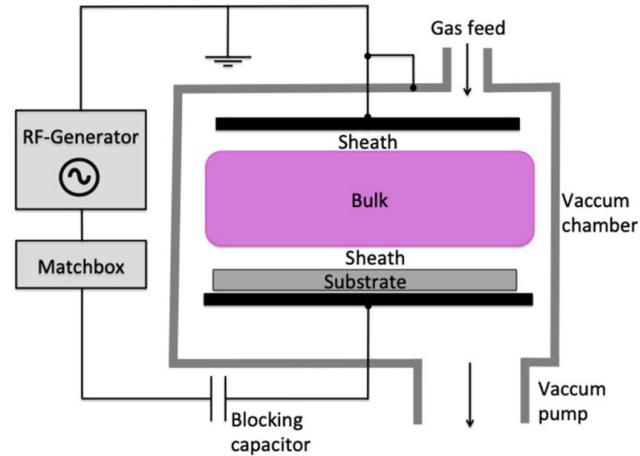
Denis Eremin

Institute of Theoretical Electrical Engineering, Ruhr University Bochum



Motivation

CCP reactor

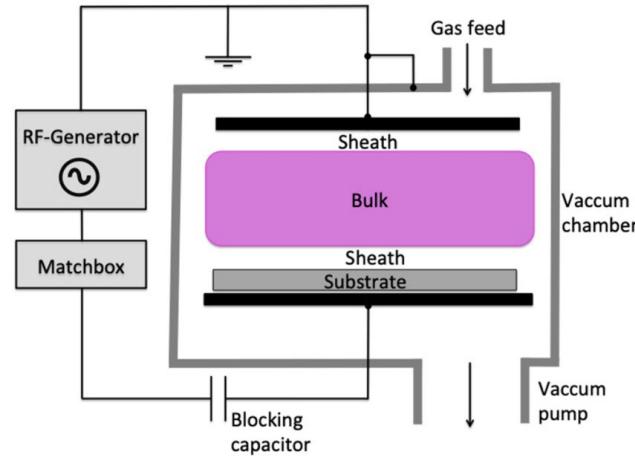


[S. Wilczek et al., J. Appl. Phys. 127 (2020)] 181101]

- Higher driving frequency leads to higher ion flux
- Larger wafer size increases throughput
- Plasma (ion flux and energy) uniformity issues

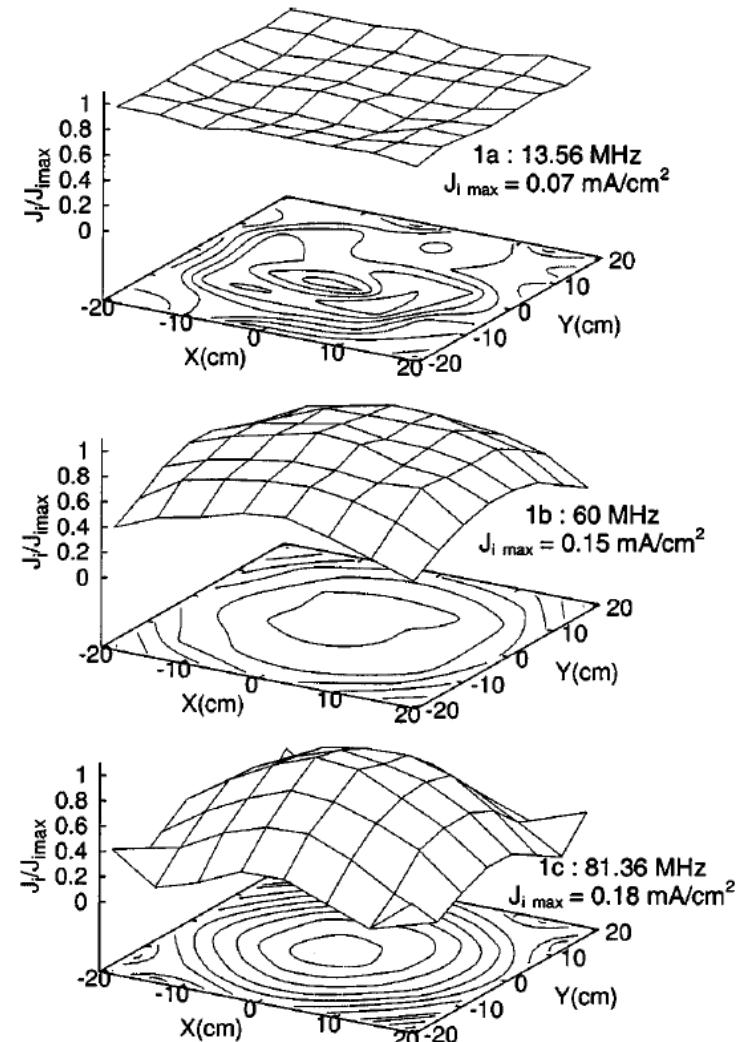
Motivation

CCP reactor



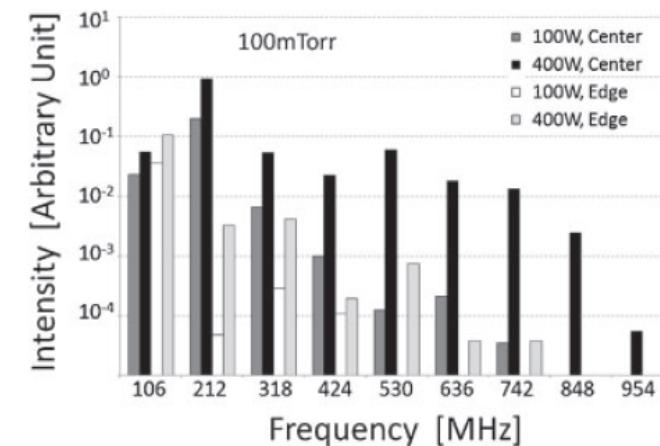
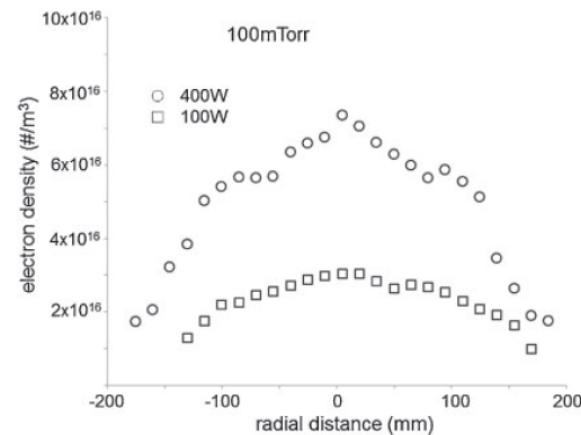
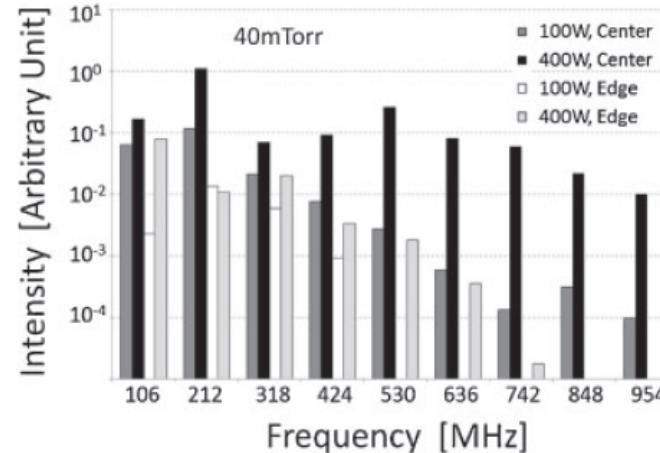
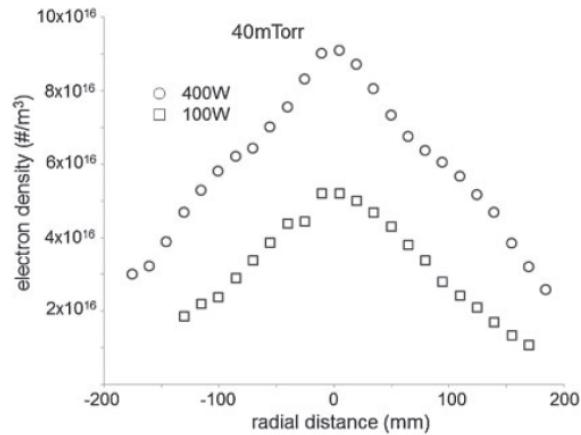
[S. Wilczek et al., J. Appl. Phys. 127 (2020)] 181101]

- Higher driving frequency leads to higher ion flux
- Larger wafer size increases throughput
- Plasma (ion flux and energy) uniformity issues



[A. Perret et al., Appl. Phys. Lett. 83 (2003) 243]

Tokyo Electron Measurements: Test-bench B



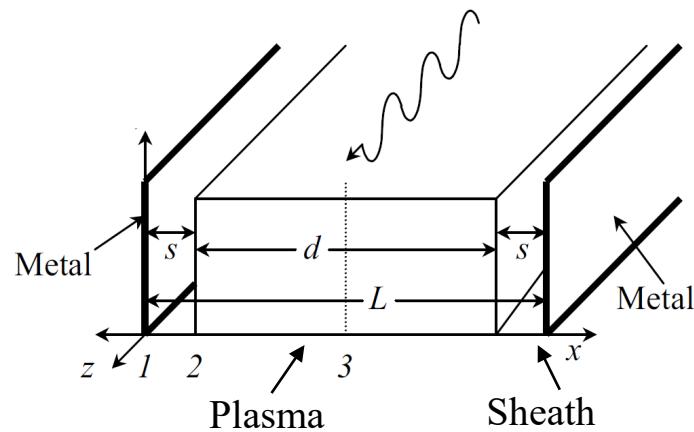
[I. Sawada et al, Jpn. J. Appl. Phys. 53 (2014) 03DB01]

Theory: Normal Modes in a CCP Discharge

Surface Waves in a Cartesian Slab CCP

[K. Bowers, PhD. Thesis, UC Berkeley, 2001,

"High Frequency Electron Resonances and Surface Waves in Unmagnetized Bounded Plasmas"]



$$\epsilon_r = 1 - \omega_{pe}^2 / \omega^2 \quad \epsilon_r = 1$$

$$\begin{cases} \frac{d\tilde{E}_z}{dx} = i(\omega\tilde{B}_y - k\tilde{E}_x) \\ \tilde{B}_y = \frac{\omega\epsilon_r}{kc^2}\tilde{E}_x \\ \frac{d\tilde{B}_y}{dx} = \frac{i\omega\epsilon_r}{c^2}\tilde{E}_z \end{cases}$$

$$\Rightarrow \frac{d^2\tilde{E}_z}{dx^2} - \left(k^2 - \frac{\omega^2\epsilon_r}{c^2} \right) \tilde{E}_z = 0$$

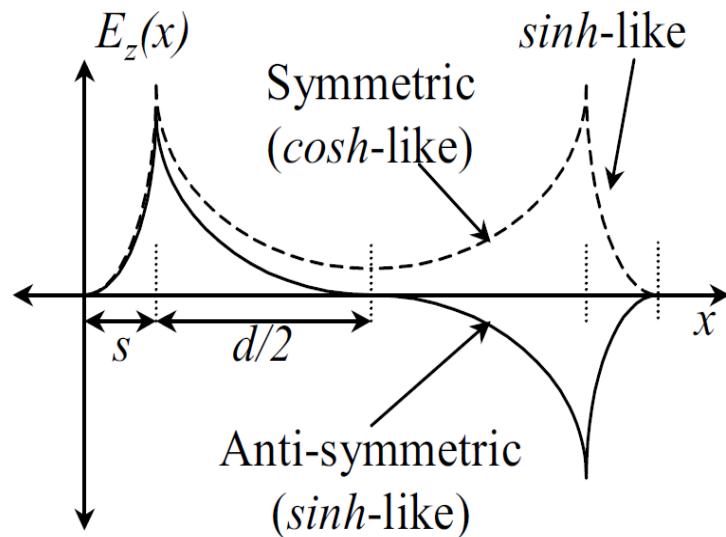
Solution: $\tilde{E}_z = Ae^{\alpha x} + Be^{-\alpha x}$ with $\alpha^2 = k^2 - \omega^2\epsilon_r/c^2$

Boundary & matching conditions at $x = 0, L$ and $x = s, L/2 - s$

and symmetry condition $\tilde{E}_z(x = L/2) = 0$ (anti-symmetric)

$\tilde{E}_z(x = s) = \tilde{E}_z(x = L/2 - s)$ (symmetric)

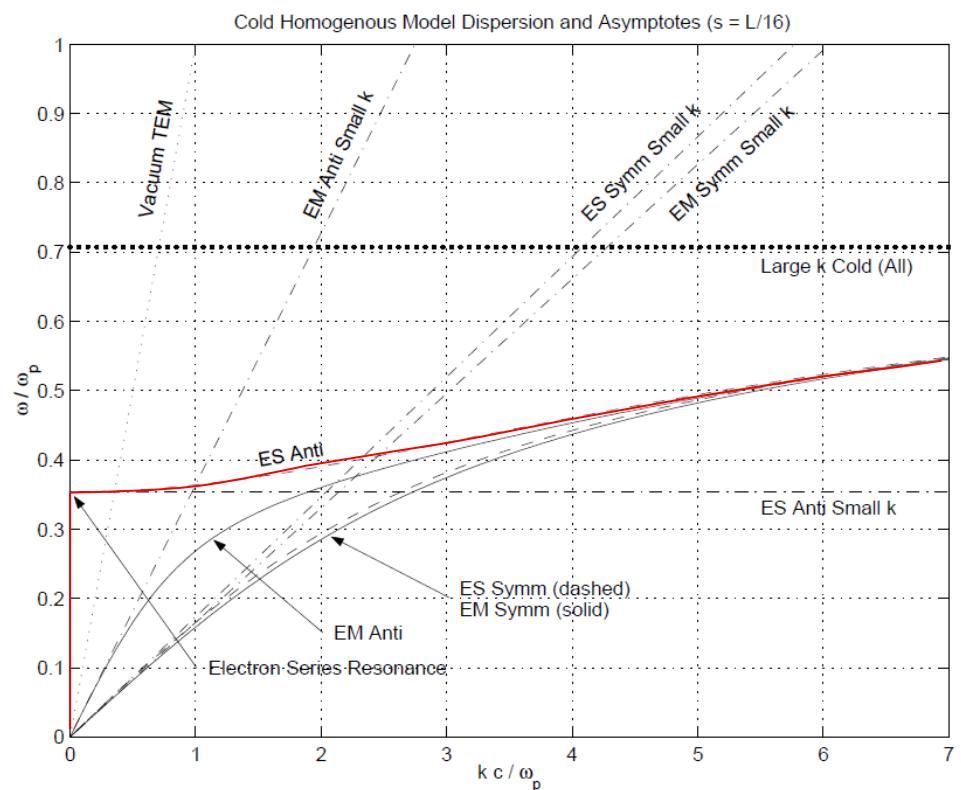
Dispersion Curves of Surface Waves



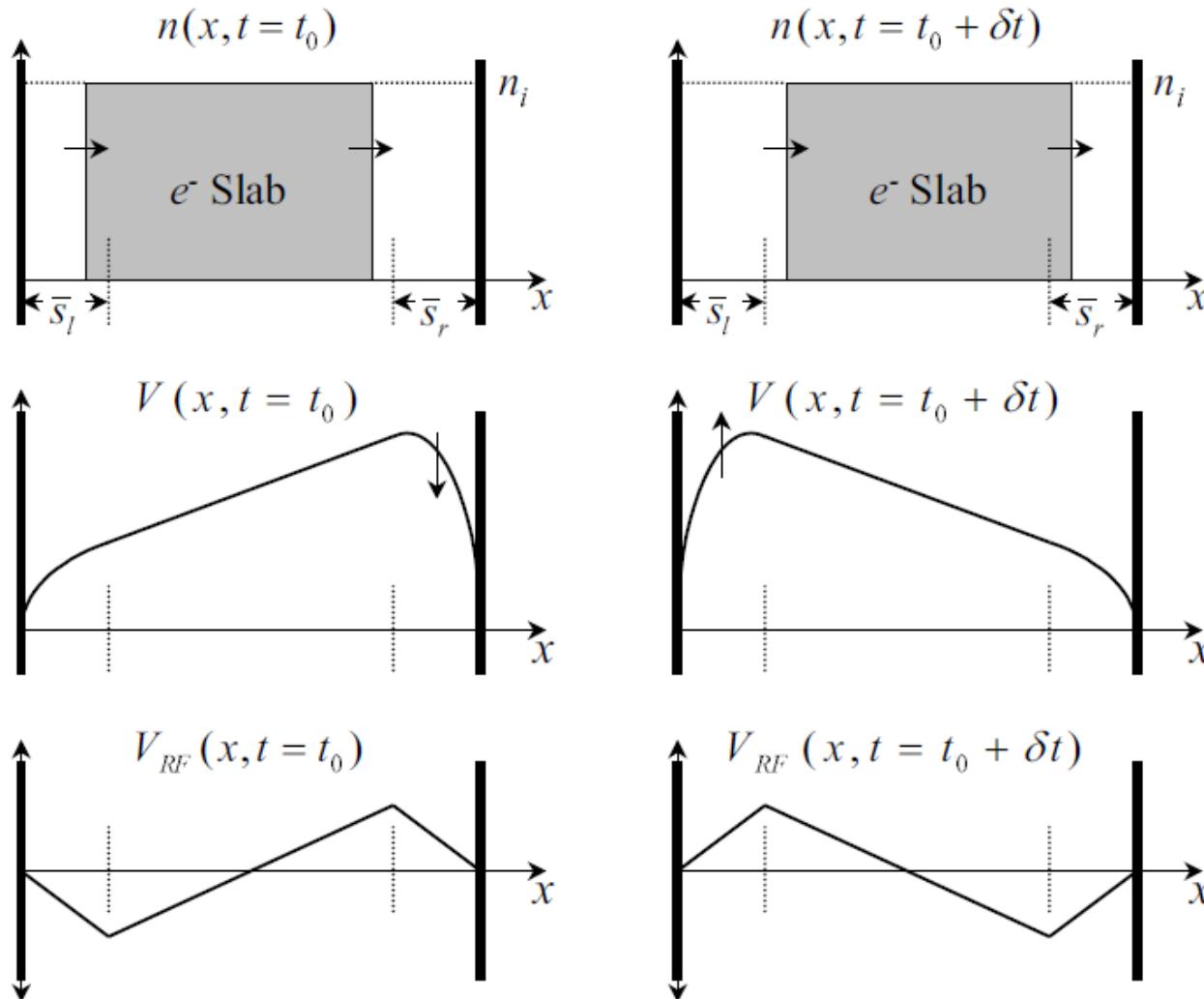
$$\coth \alpha s = \frac{\alpha}{\beta} \left(\frac{\omega_p^2}{\omega^2} - 1 \right) \coth \beta d/2 \quad \text{antisymmetric mode}$$

$$\coth \alpha s = \frac{\alpha}{\beta} \left(\frac{\omega_p^2}{\omega^2} - 1 \right) \tanh \beta d/2 \quad \text{symmetric mode}$$

$$\alpha^2 = k^2 - \omega^2/c^2 \quad \beta^2 = k^2 - \omega^2/c^2 + \omega_p^2/c^2$$



Moving vs Fixed Slab Model

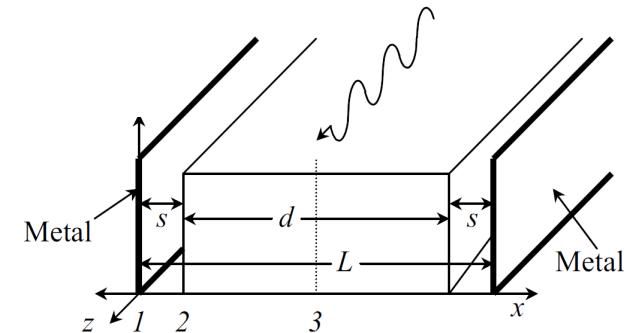
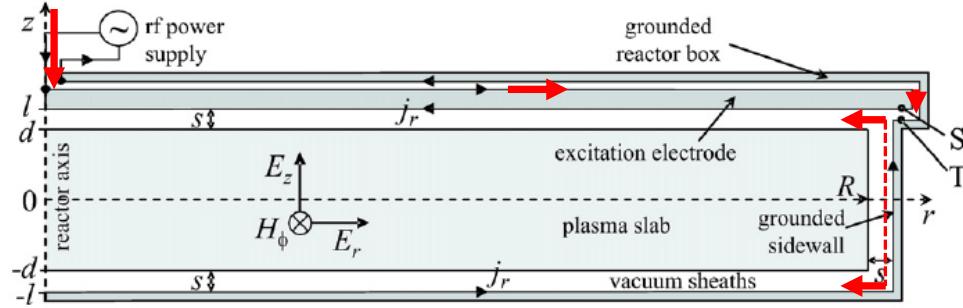


Moving and fixed slab models are equivalent for small amplitudes

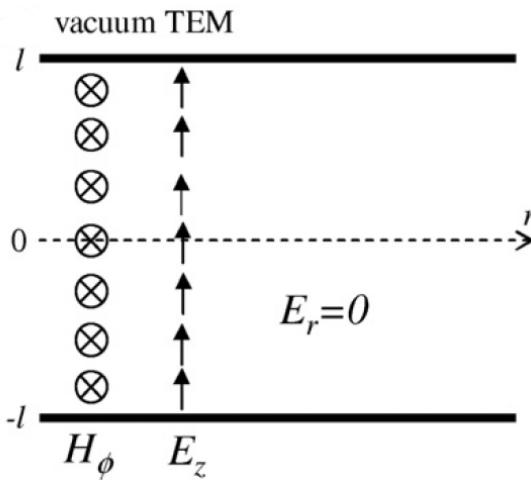
Normal modes in a cylindrical CCP

[A.A. Howling et al, Thin Solid Films 515 (2007) 5059]

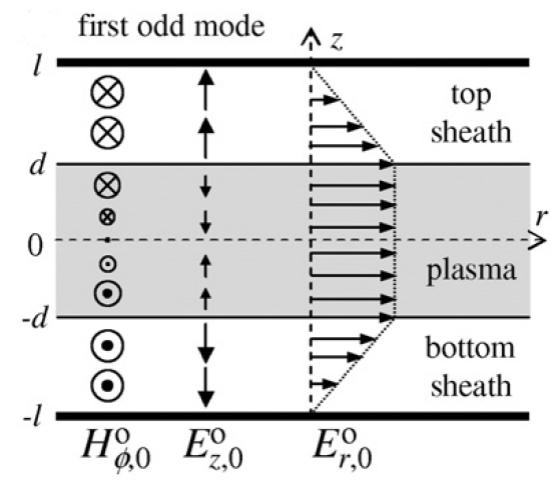
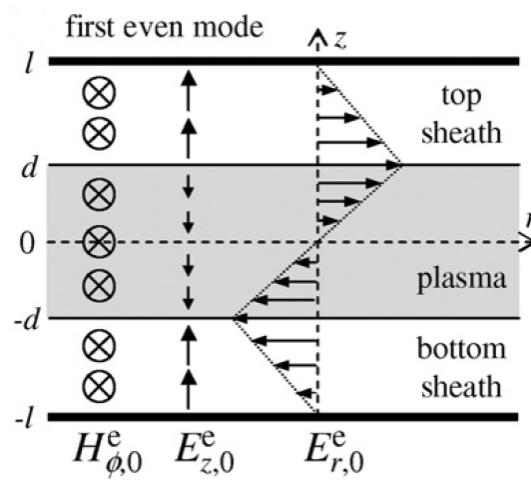
[L. Sansonnens et al, Plasma Sources Sci. Technol. 15 (2006) 302]



no plasma, TEM mode

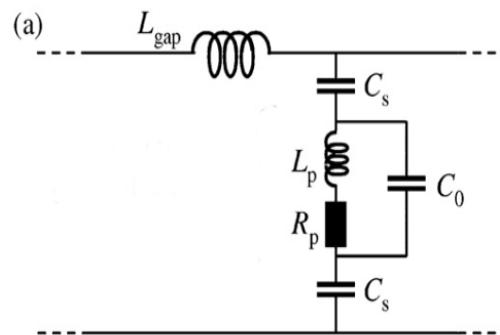
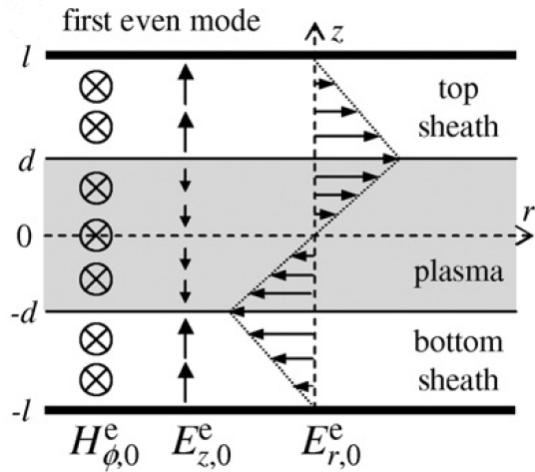


with plasma, two quasi-TEM modes



See also [M. Lieberman et al, Phys. Plasmas 23 (2016) 013501]

Even (Symmetric) Mode: Always Around



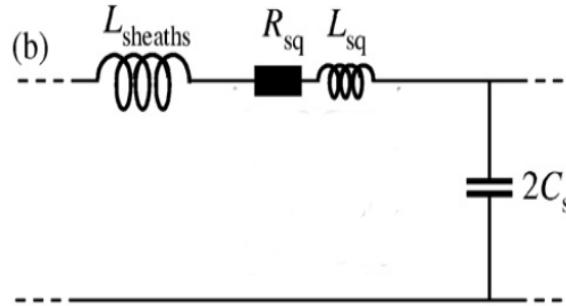
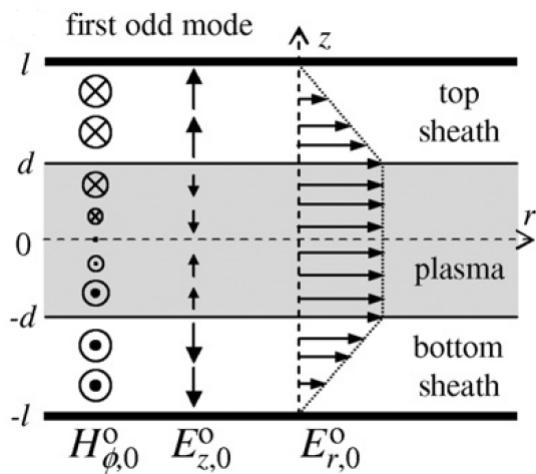
Compared to the vacuum case, effective relative permittivity is

$$\varepsilon_{\text{eff}} = \frac{s + d}{s}$$

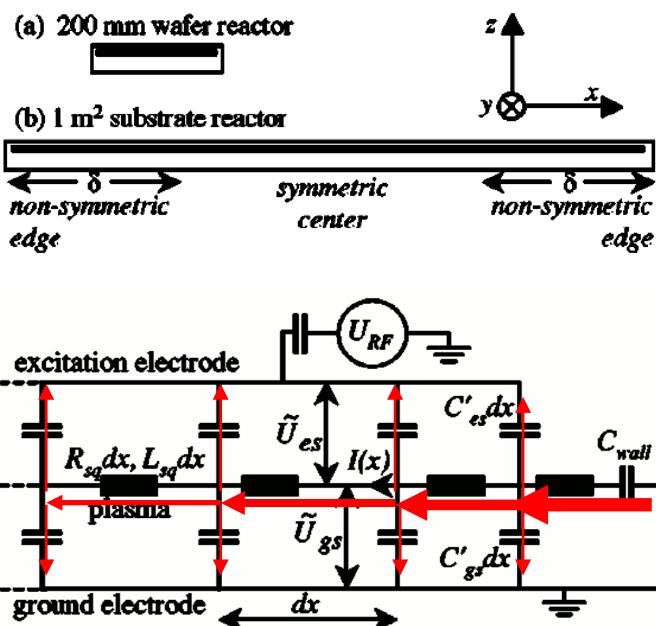
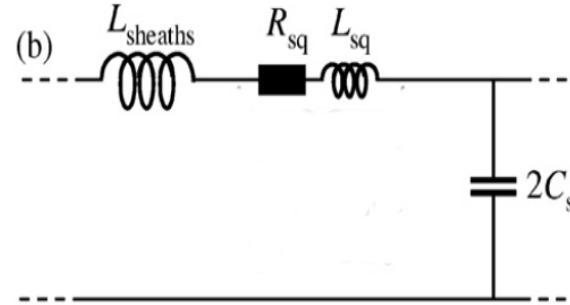
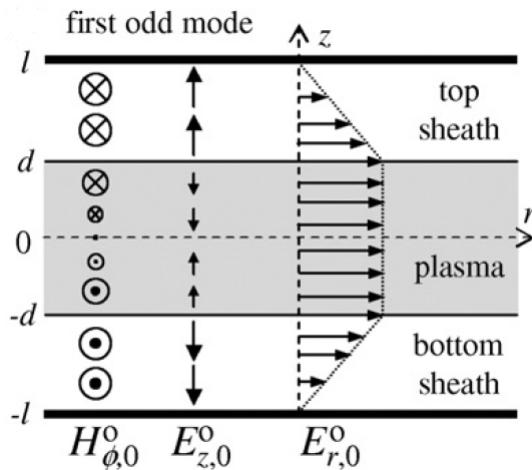
Therefore, the effective EM velocity is

$$c_{\text{eff}} = c / \sqrt{\varepsilon_{\text{eff}}} = c / \sqrt{1 + d/s} \ll c$$

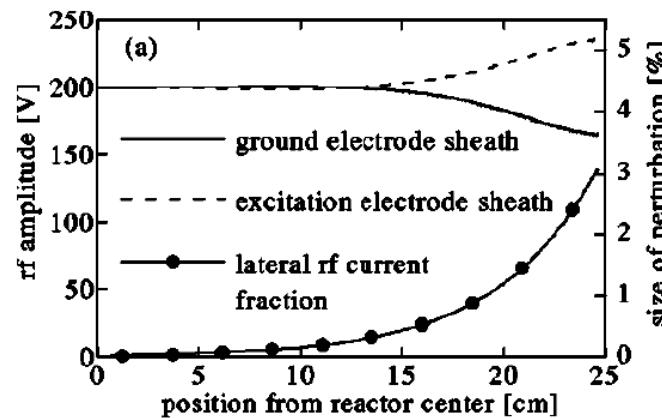
Physical Nature of the Odd (Antisymmetric) Mode



Physical Nature of the Odd (Antisymmetric) Mode

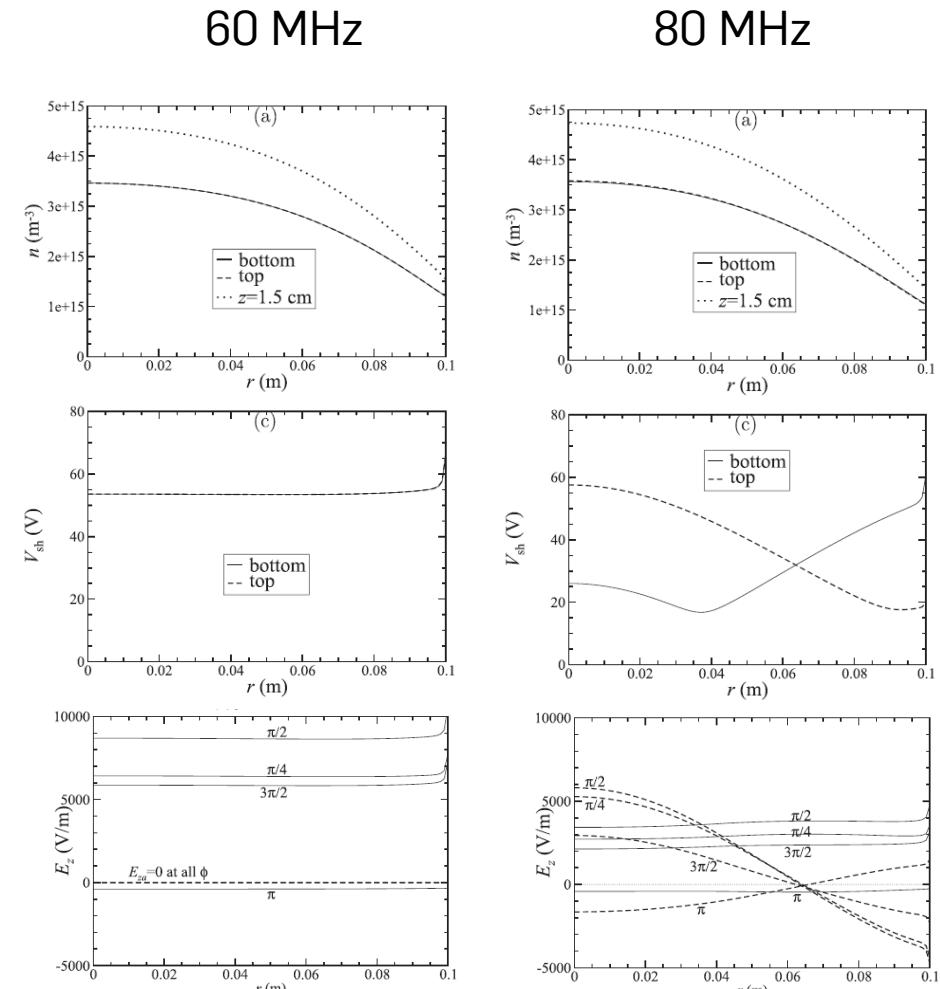
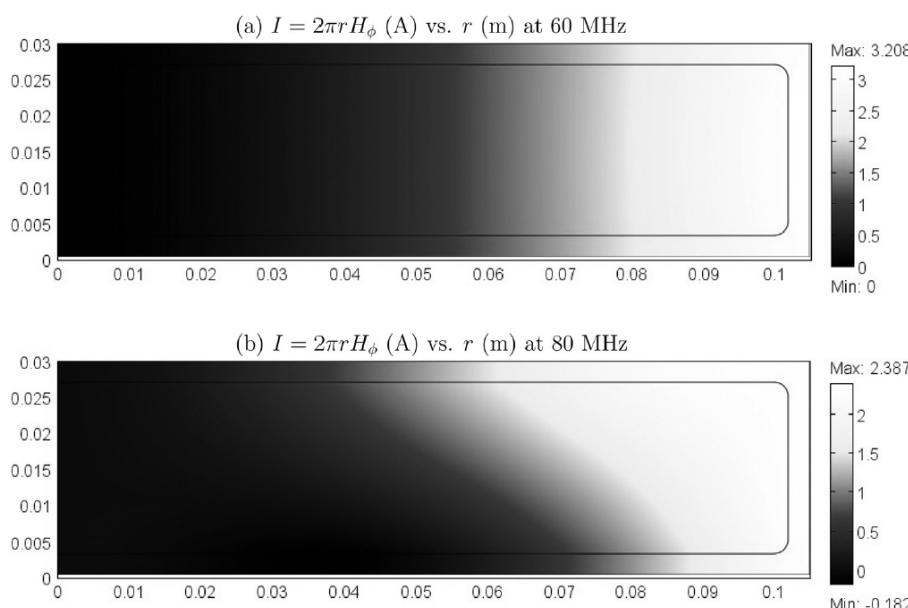
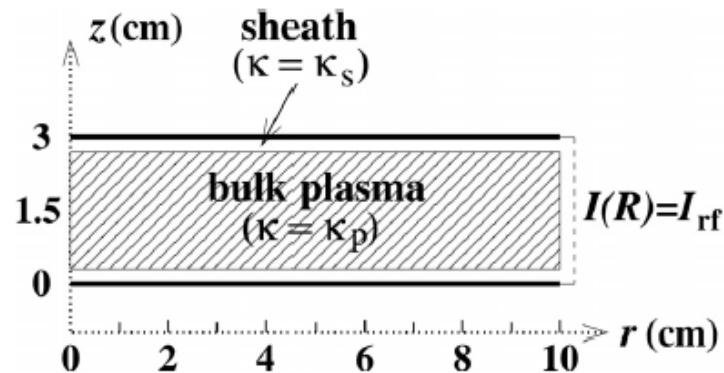


Radially nonuniform rf plasma potential!



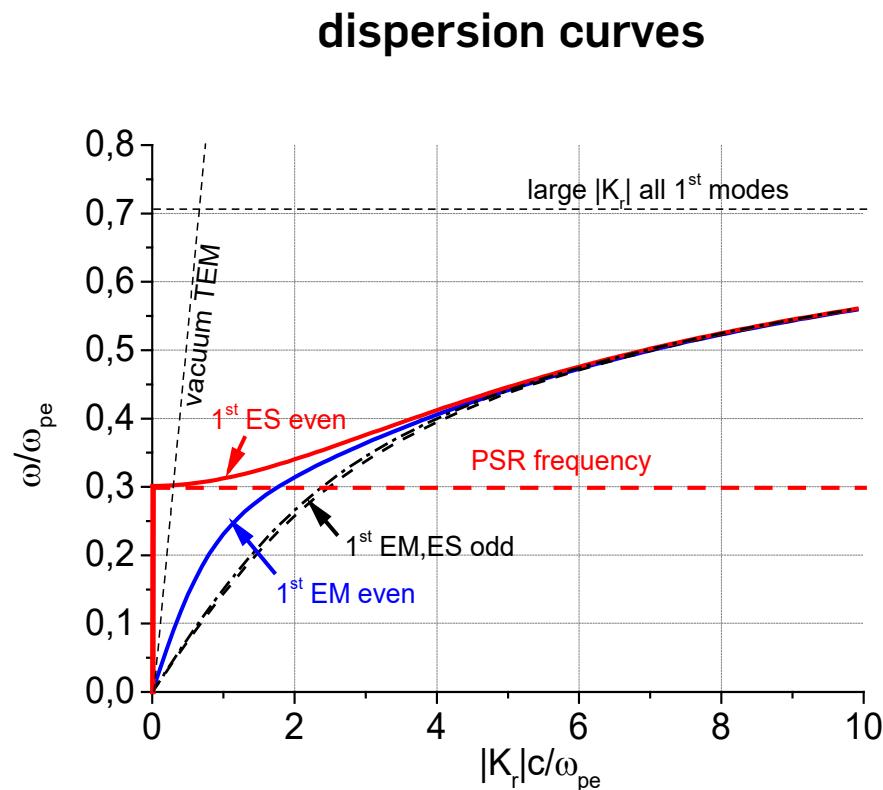
[A.A. Howling et al., J. Appl. Phys., 96, 5429 (2004)]

Excitation of the Odd Mode and Symmetry Breaking



[E. Kawamura et al., Phys. Plasmas, 25, 093517 (2018)]

Dispersion Curves



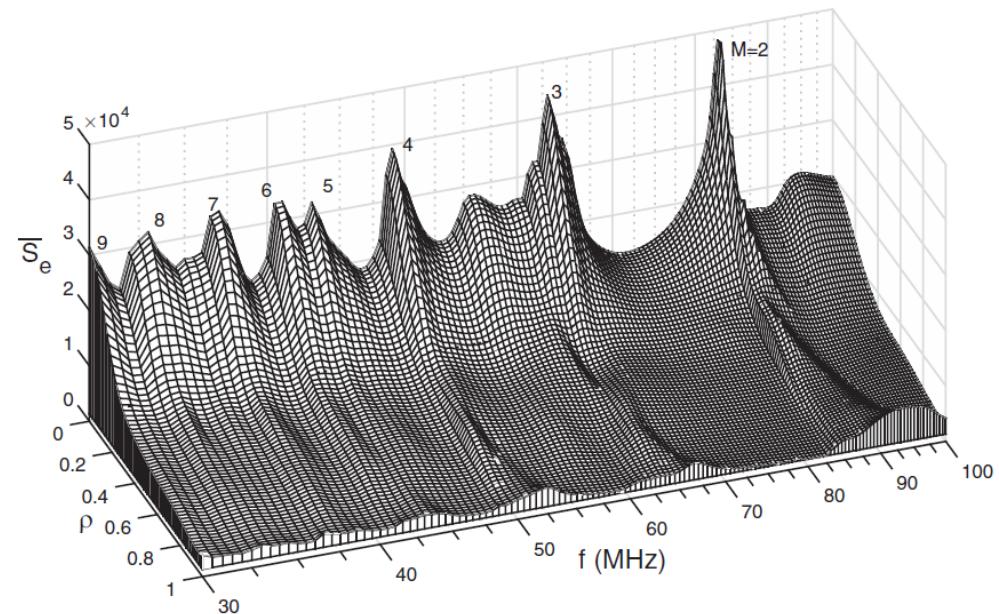
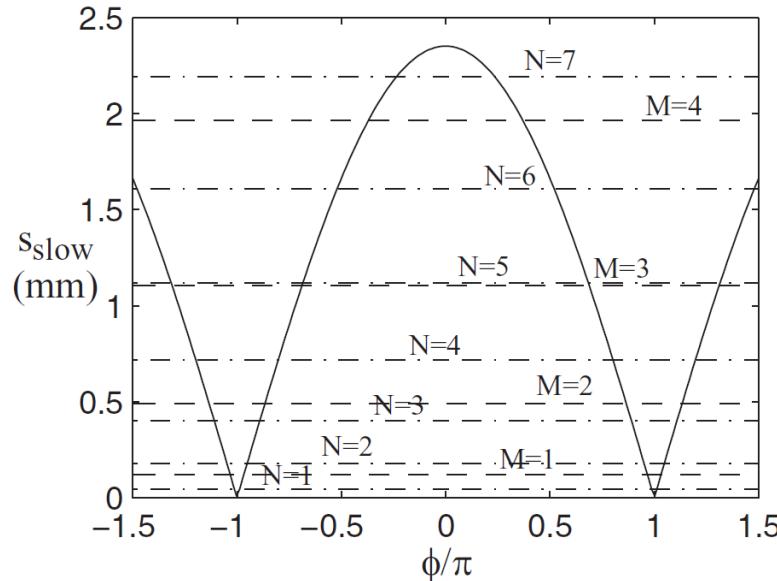
Electron drift diffusion-based fluid models are not sufficient:
[D. Eremin, IEEE Trans. Plasma Sci. 45(4) (2017) 527]

Spatial Mode Resonances

[M.A. Lieberman et al., Plasma Sources Sci. Technol. 24, 055011, (2015)]

PSR resonance: $N\omega = \omega_{PSR} = \omega_{pe} \sqrt{\frac{s}{l}}$

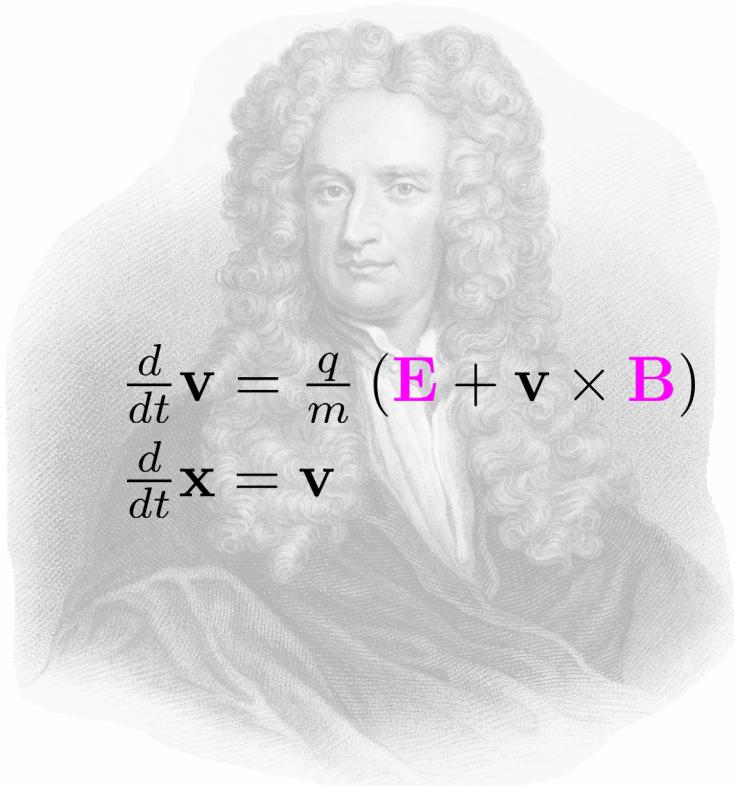
Spatial resonance: $k \approx \frac{\omega_{SW}}{c} \sqrt{\frac{l}{s}} = \frac{\chi_{0m}}{R}$ $\Rightarrow \omega_{SW} = M\omega = \frac{c\chi_{0m}}{R} \sqrt{\frac{s}{l}}$



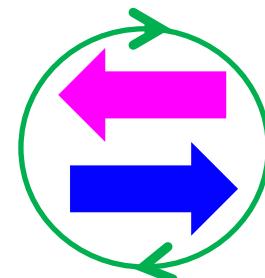
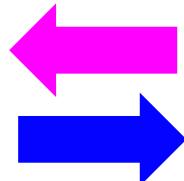
PIC Simulations of Normal Mode Excitation in CCPs

Particle-in-Cell (PIC) Algorithm

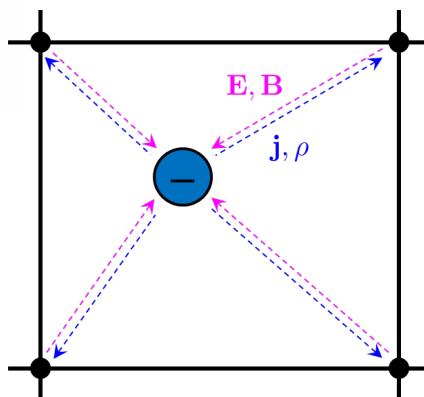
(Super)particles



decoupled over Δt
(explicit)



coupled over Δt
(implicit)



Grid

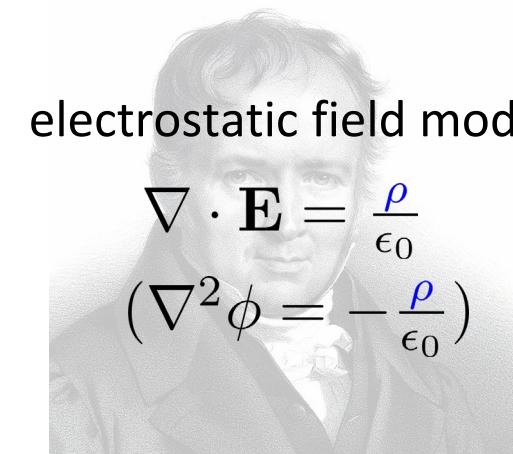
electromagnetic field model

$$\frac{\partial}{\partial t} \mathbf{E} = c^2 \nabla \times \mathbf{B} - \frac{\mathbf{j}}{\epsilon_0}$$

$$\frac{\partial}{\partial t} \mathbf{B} = -\nabla \times \mathbf{E}$$

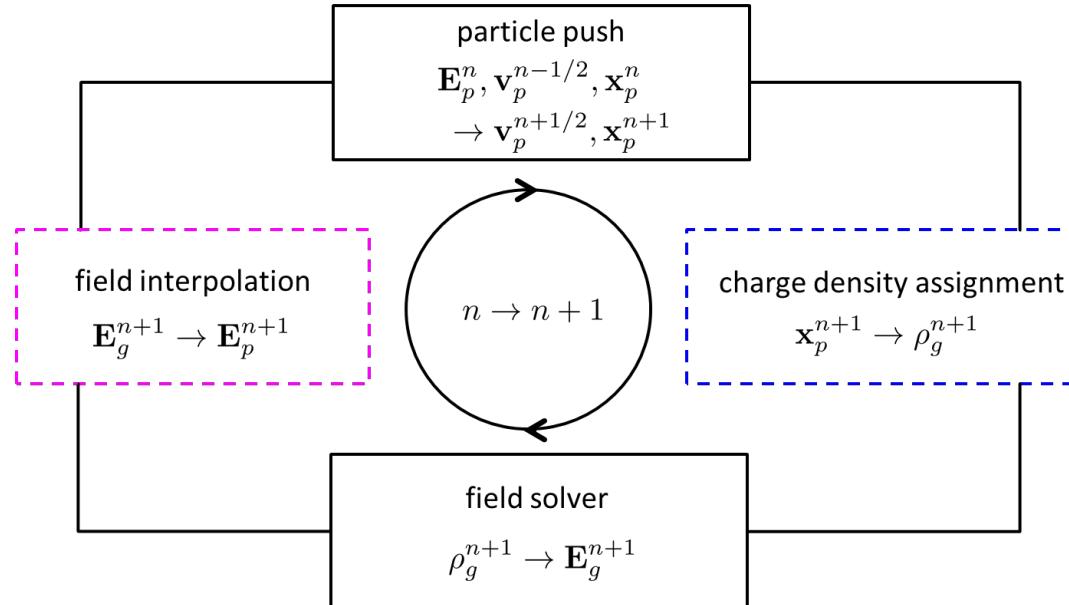
$$\nabla \cdot \mathbf{E} = \frac{\rho}{\epsilon_0}$$

$$\nabla \cdot \mathbf{B} = 0$$



electrostatic field model

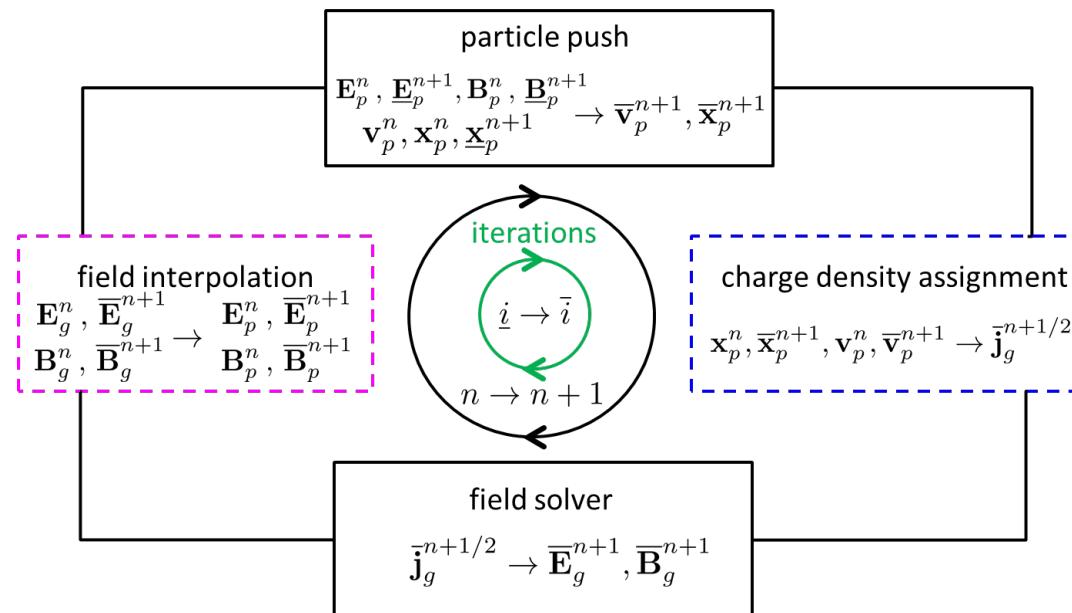
Explicit Electrostatic PIC



Simple algorithm:

- Detached evolution of fields and particles during a time step
- Exact momentum conservation, but numerical heating
- **Restrictive stability conditions** $\Delta x < \lambda_{De}$, $\Delta t < \omega_{pe}^{-1}$

Energy-conserving implicit electromagnetic PIC



Advanced algorithm:

- Consistent evolution of fields and particles during a time step
 - Exact energy conservation, thus no numerical heating
 - High numerical stability independent of the plasma density
 - Formulation for non-uniform grids to resolve, e.g., sheaths

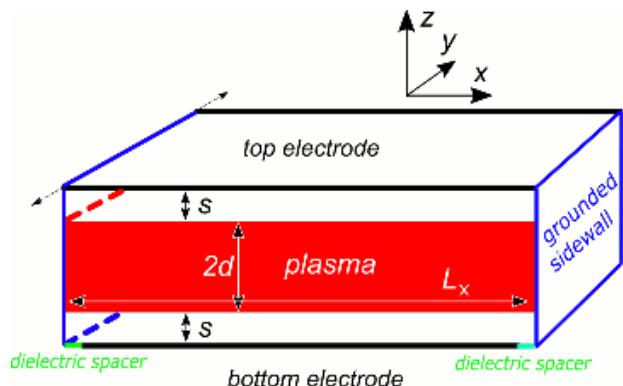
[S. Markidis and G. Lapenta, J. Comput. Phys. 230 (2011) 7037]

[G. Chen and L. Chacon, D.C. Barnes, J. Comput. Phys. 230 (2011) 7018]

[D. Eremin, J. Comput. Phys. 452 (2022) 110934]

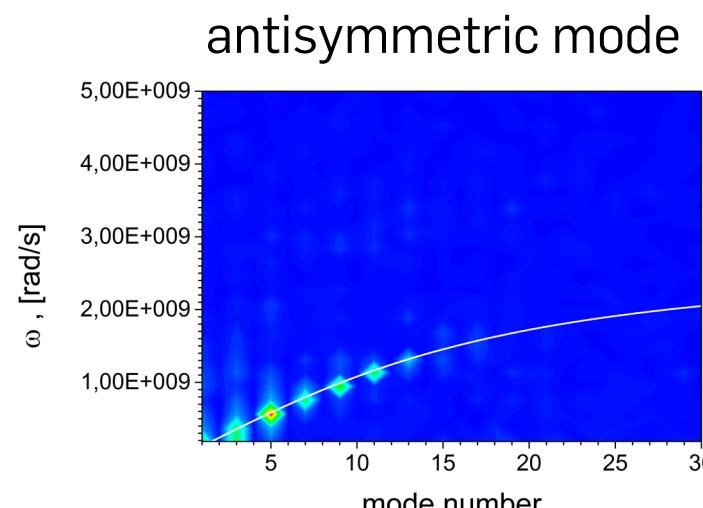
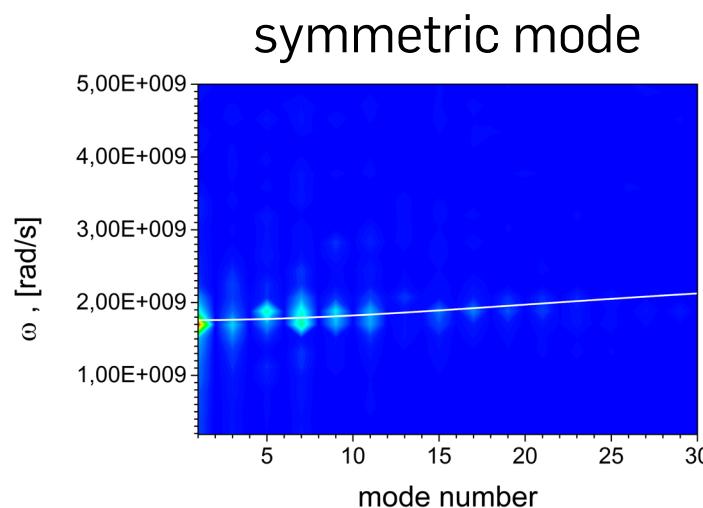
[D. Eremin et al., Plasma Sources Sci. Technol. 32 (2023) 044007]

2D ES PIC Simulations in Cartesian Geometry



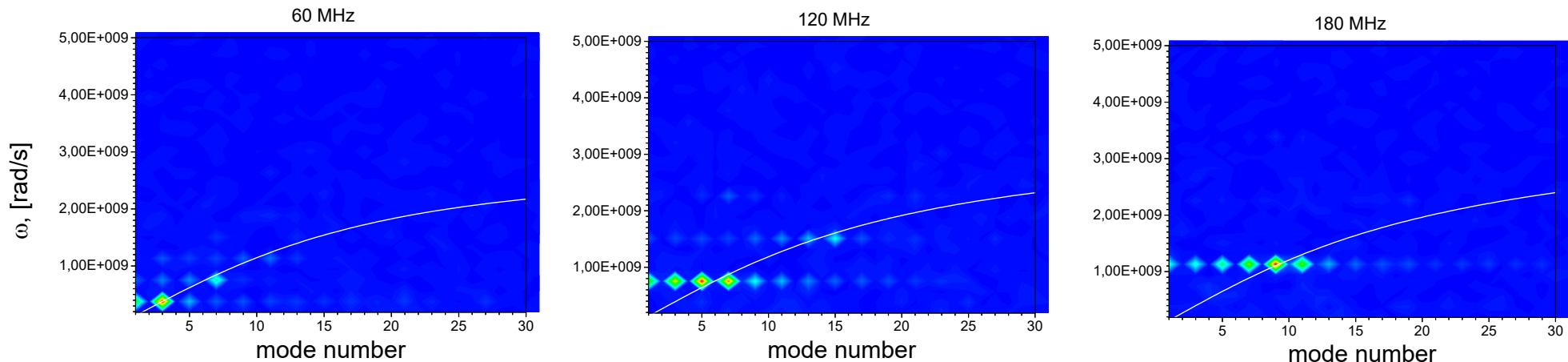
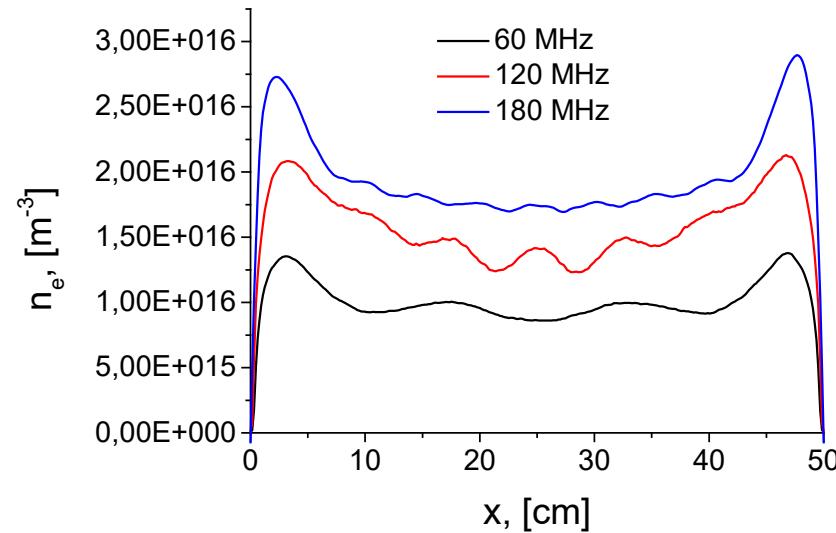
[D. Eremin et al. Plasma Process Polym. 14 (2017) 1600164]

[D. Eremin IEEE Trans. Plasma Sci. 45 (2017) 527]



$$E_z \sim \sin \left(\frac{\pi(2n-1)x}{L_x} \right)$$

Forced Excitation of the Antisymmetric Mode



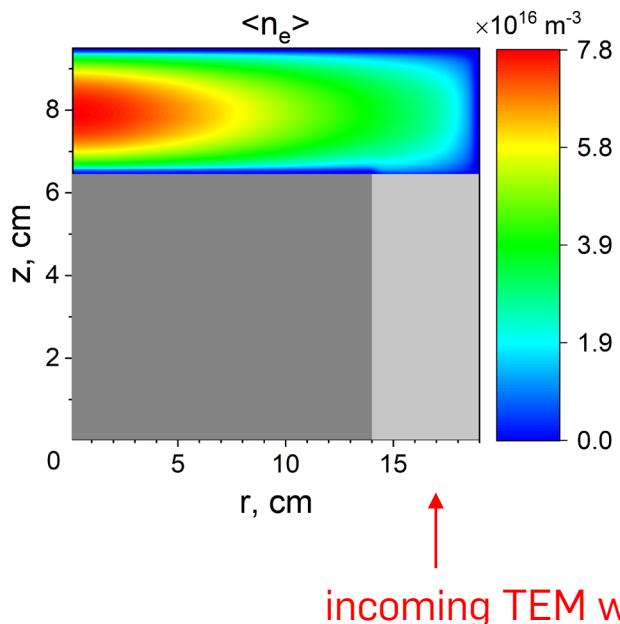
$$\omega/k \approx \omega_{pe} \sqrt{sd} \quad k \rightarrow 0$$

2D EM PIC Simulations in Cylindrical Geometry

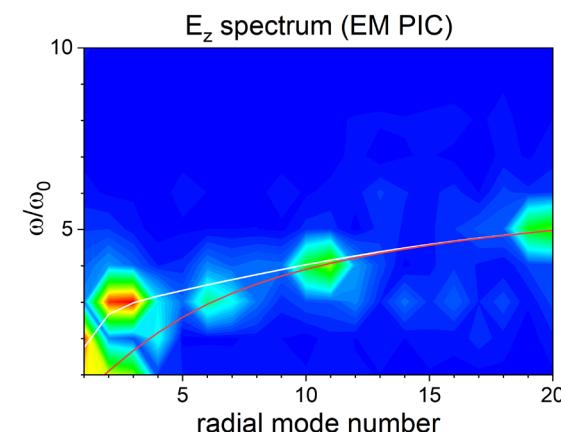
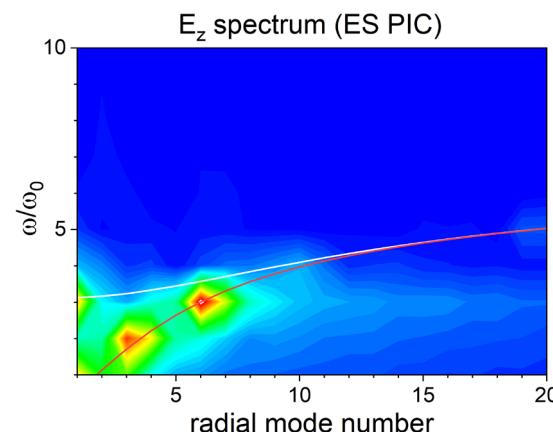
ECCOPIC2M code:

[D. Eremin et al., Plasma Sources Sci. Technol. 32 (2023) 044007]

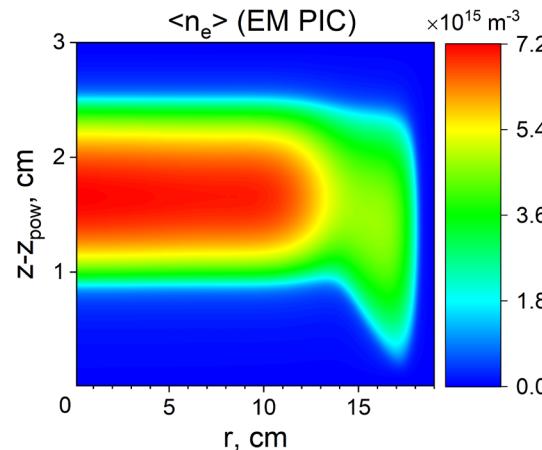
model geometry



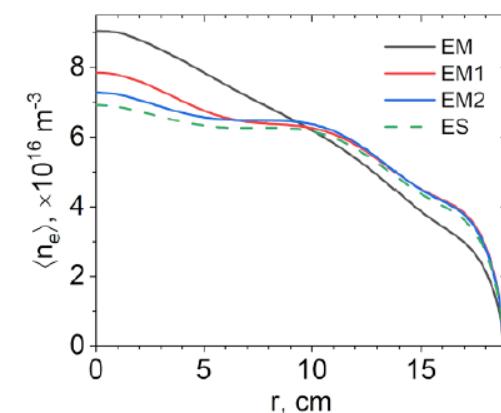
Test 1: dispersion curves: PIC vs analytical prediction



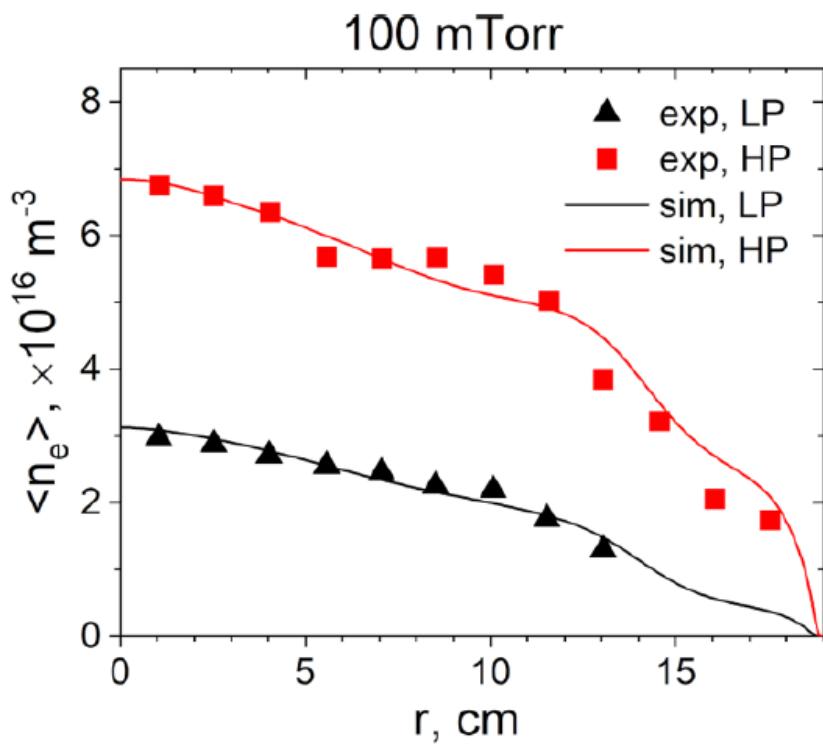
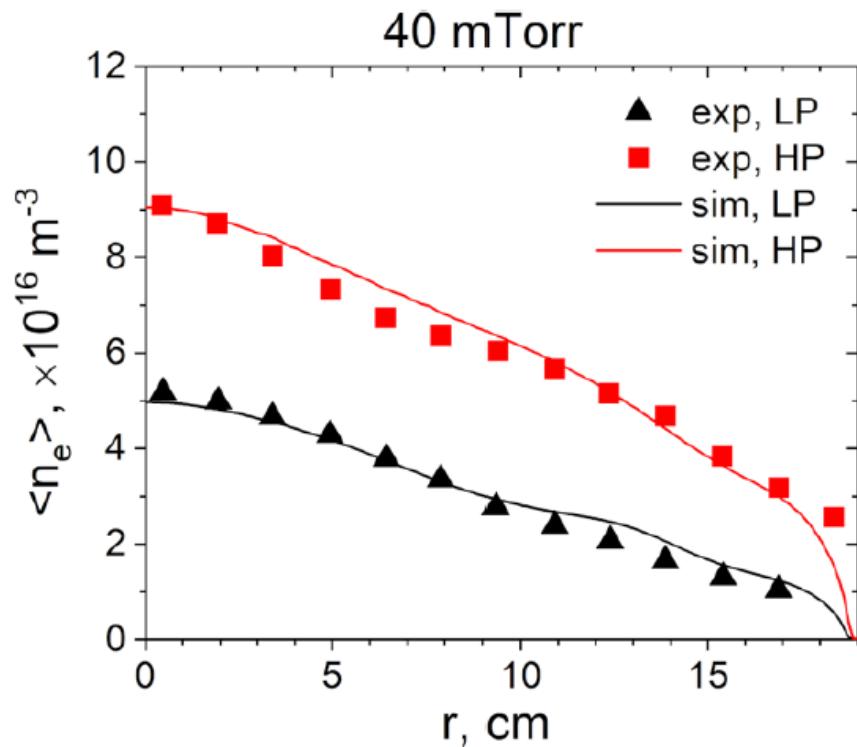
Test 2: 13.56 MHz case



Test 3: EM to ES, 106 MHz



Validation of ECCOPIC2M



electron density comparison:

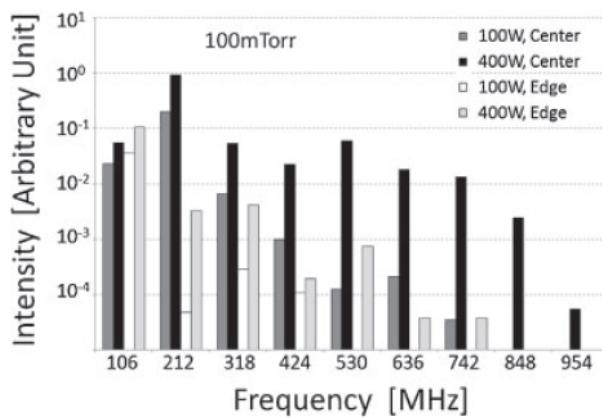
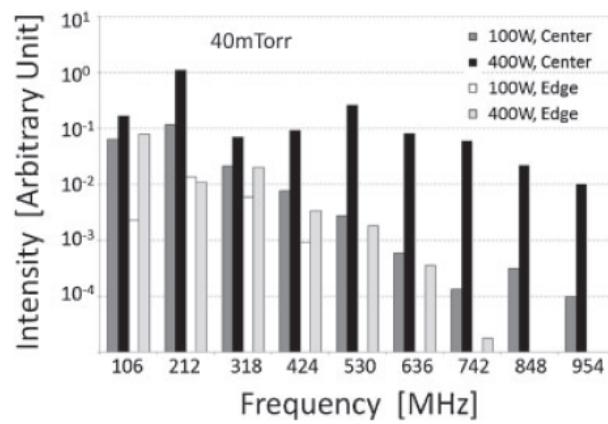
experiment [I. Sawada et al, Jpn. J. Appl. Phys. 53 (2014) 03DB01]

vs

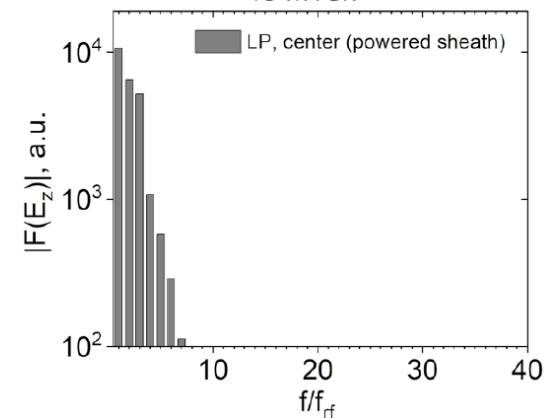
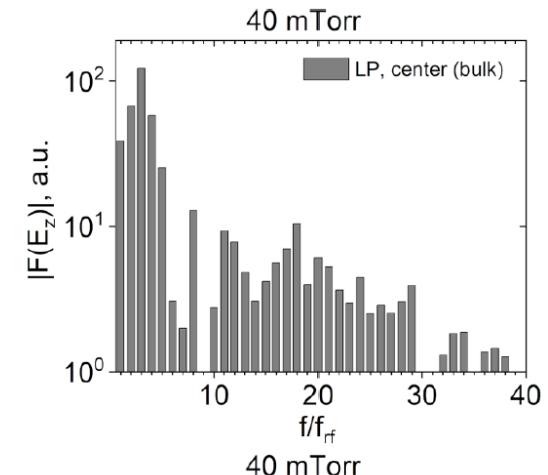
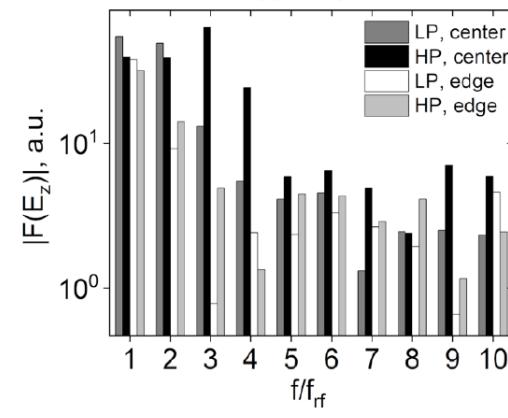
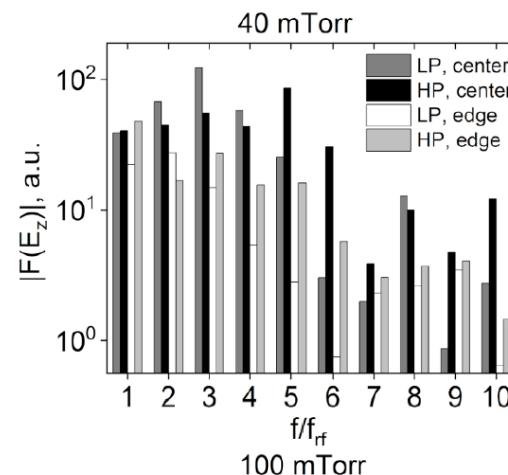
EM PIC/MCC simulations (ECCOPIC2M)

Harmonic content: experiment vs ECCOPIC2M

experiment:

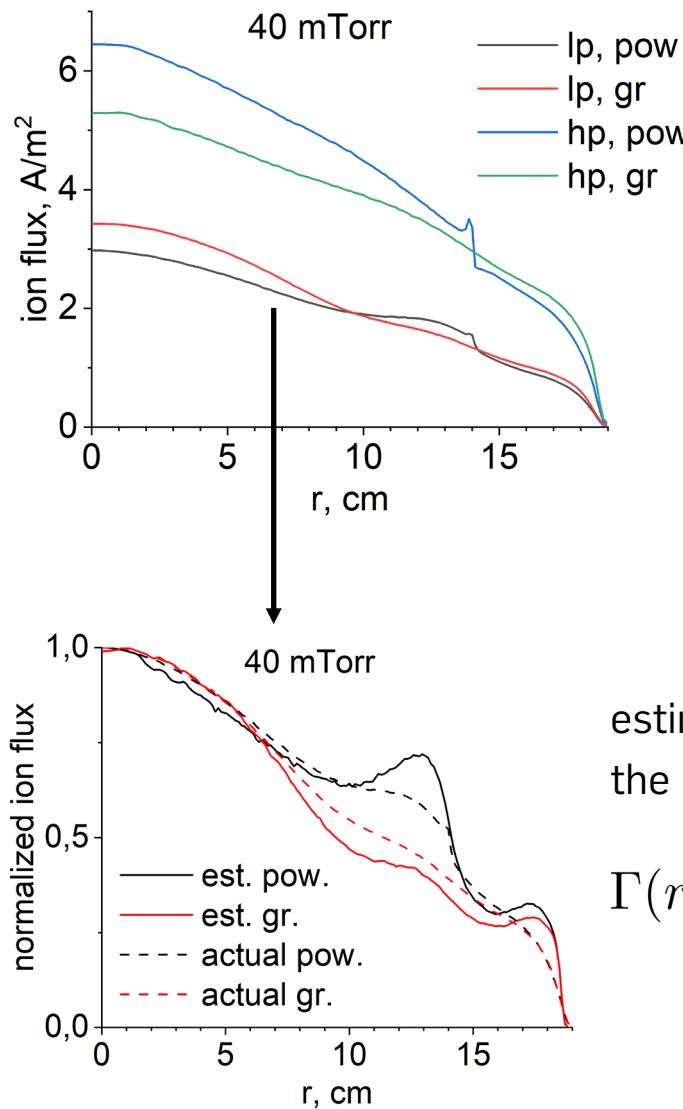


PIC/MCC simulations:

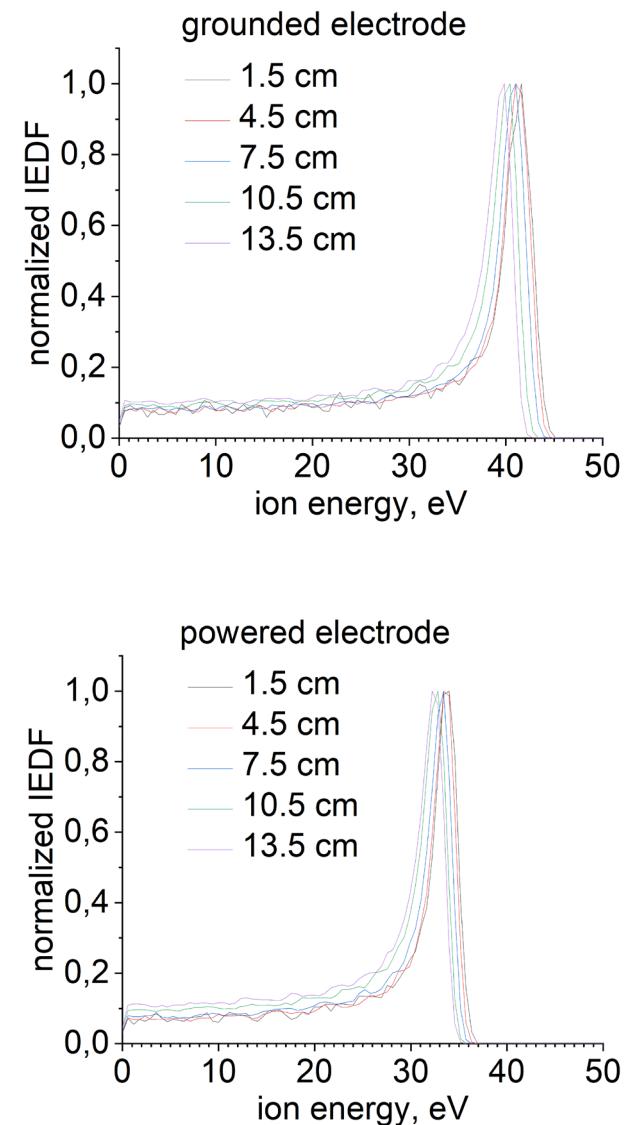


Radial Uniformity of Ion Flux and Energy

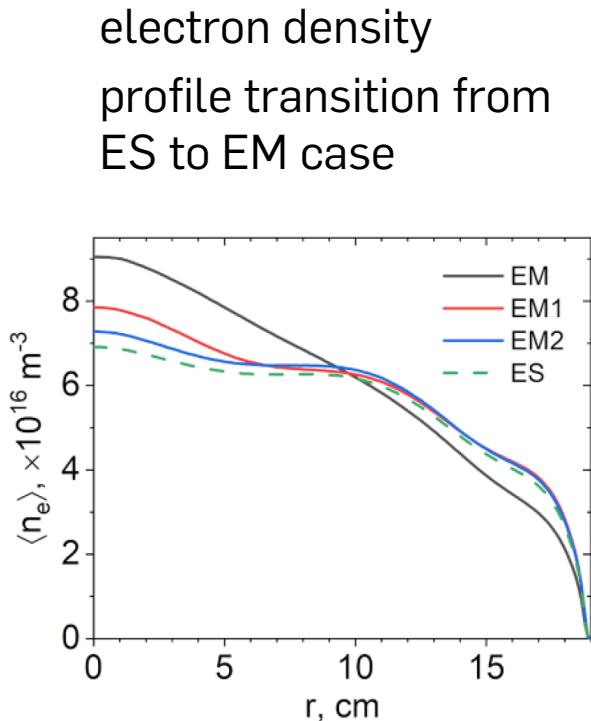
Ion flux



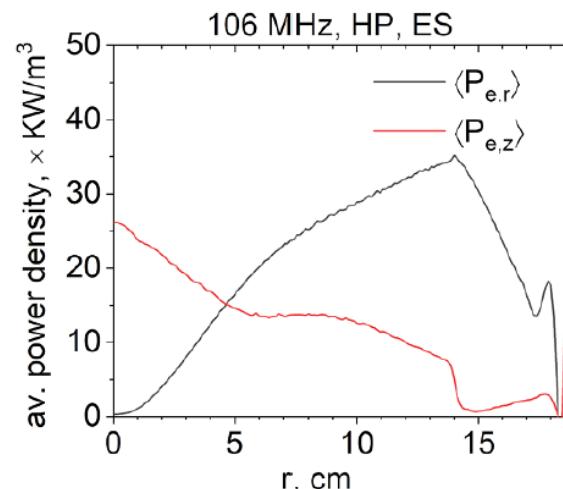
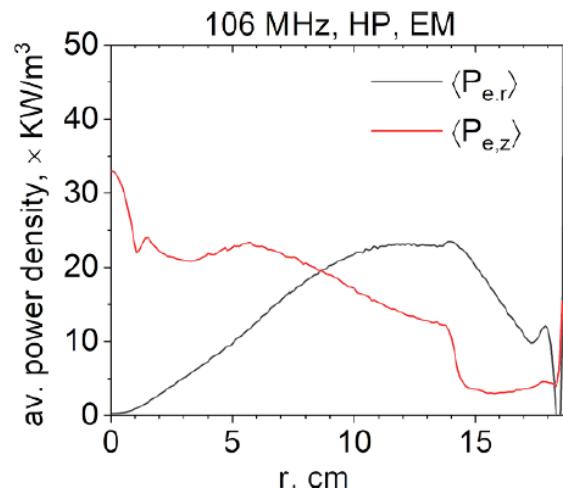
IEDF, EM PIC/MCC



Power absorption by electrons: EM vs ES



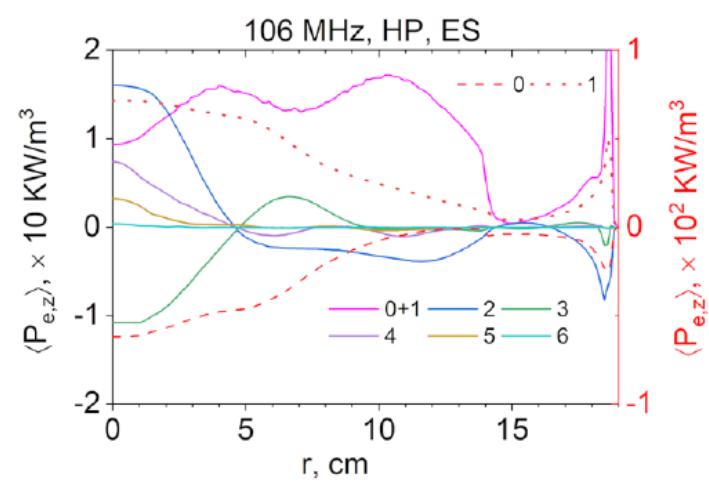
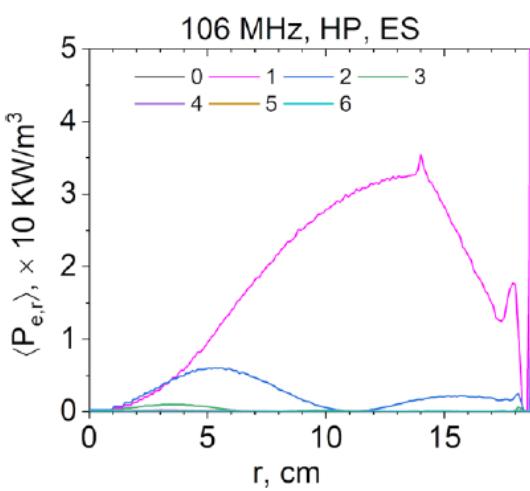
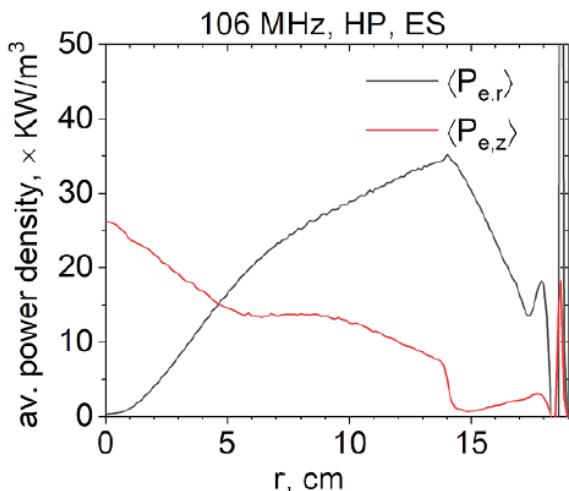
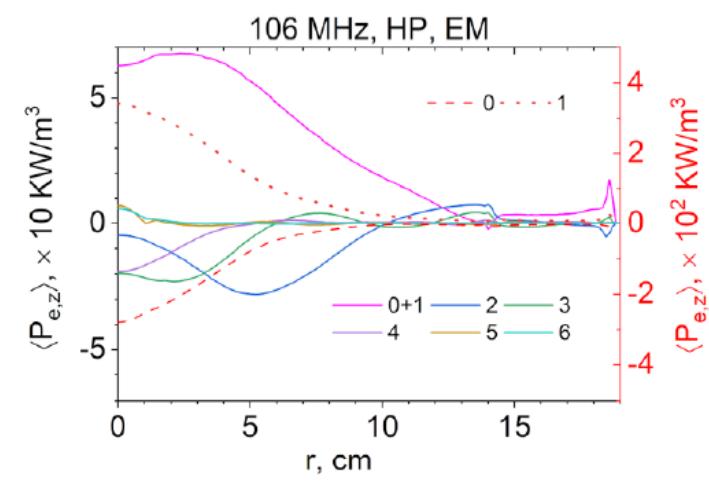
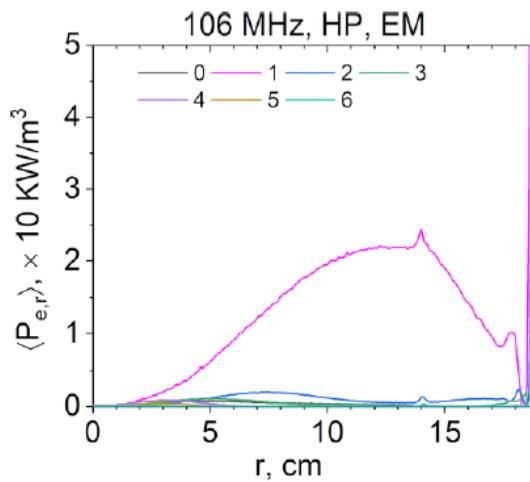
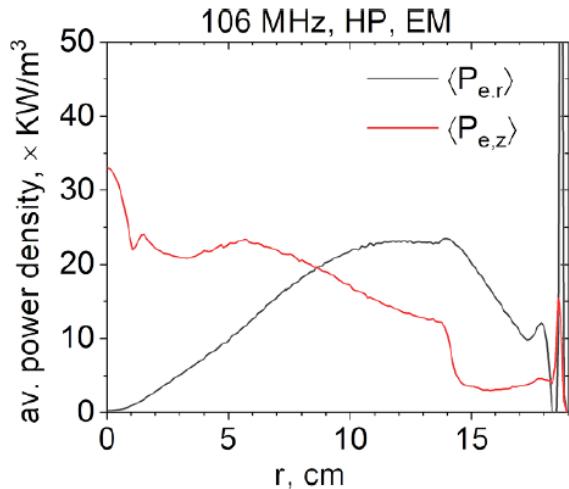
average absorbed
power profiles



Radial power absorption is
not due to the inductive
heating, but due to the
antisymmetric mode!

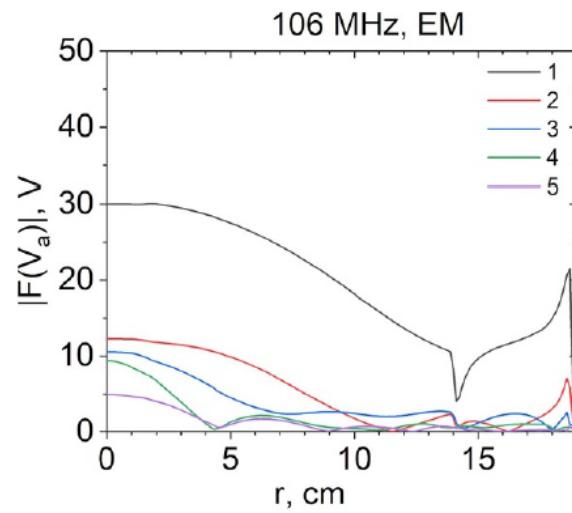
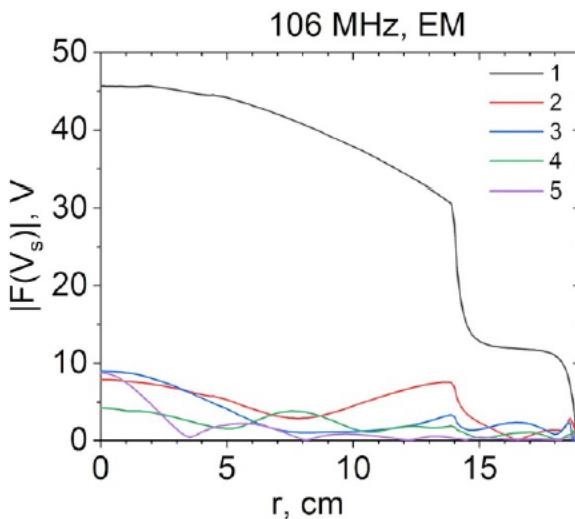
Harmonic analysis

contributions to the average power from separate harmonics

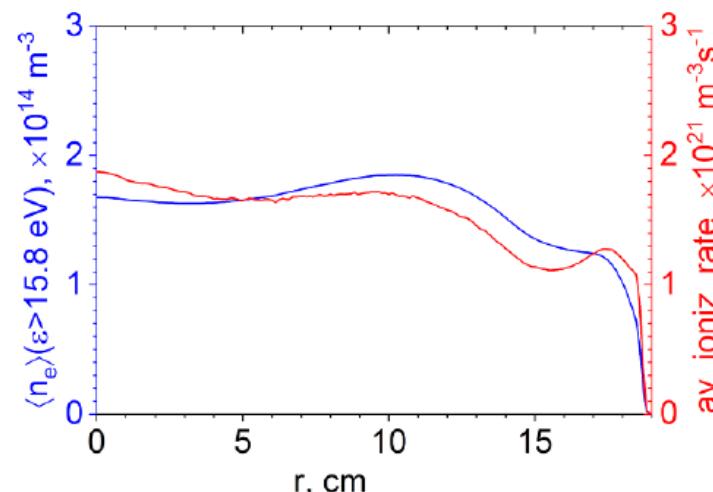
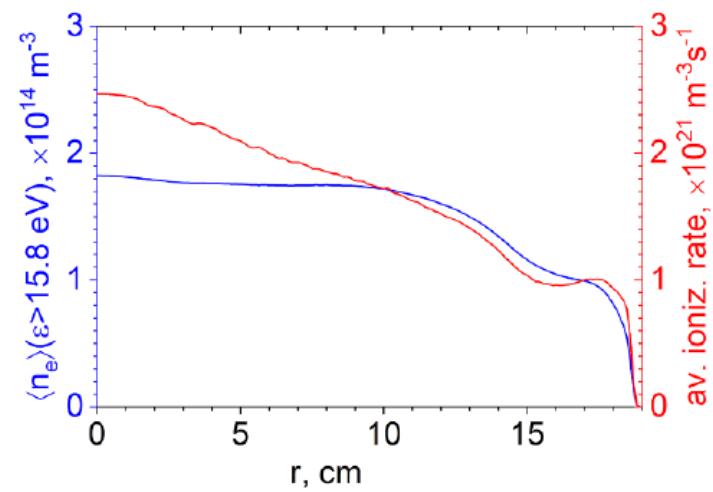


Electron Energization by Different Modes

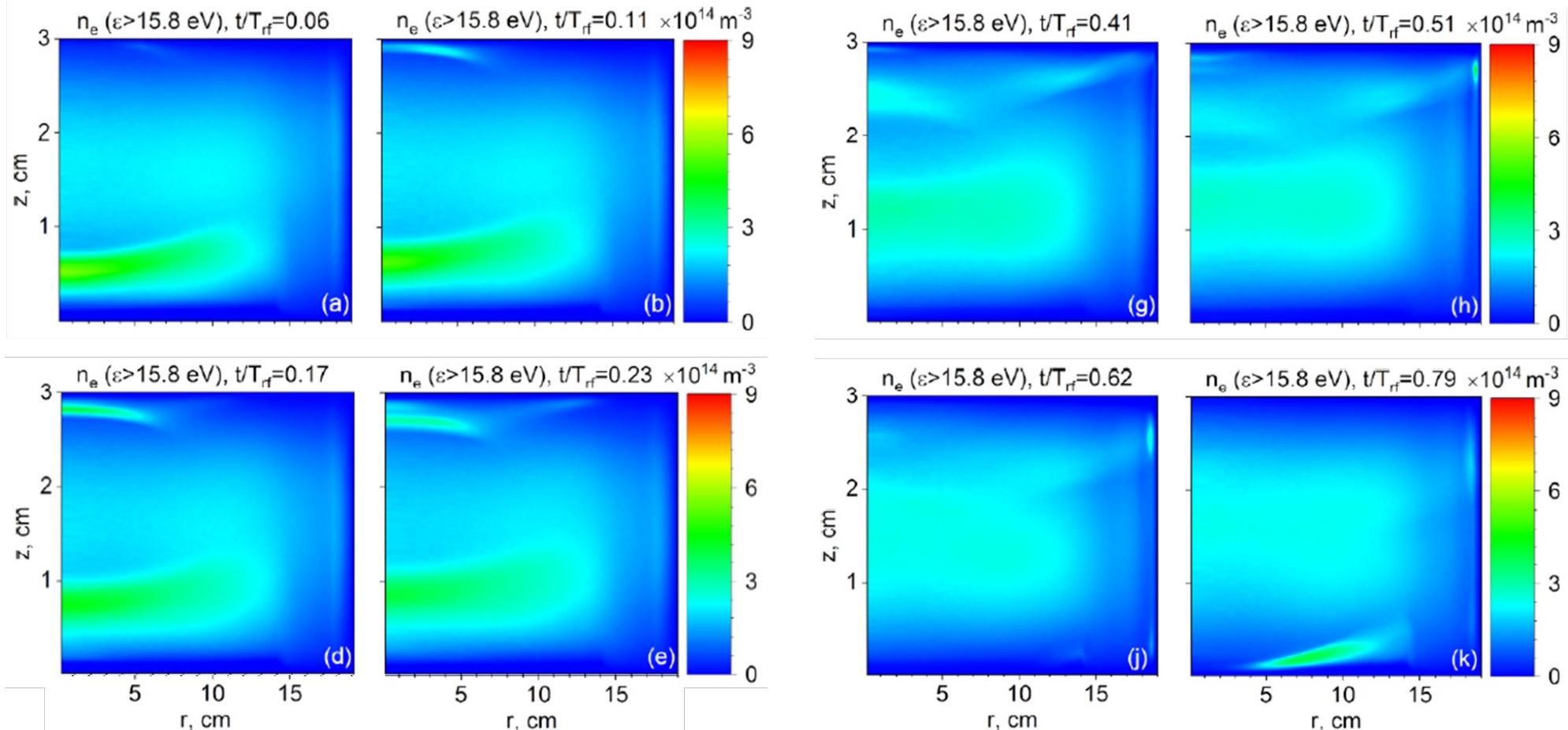
Surface mode harmonic amplitudes



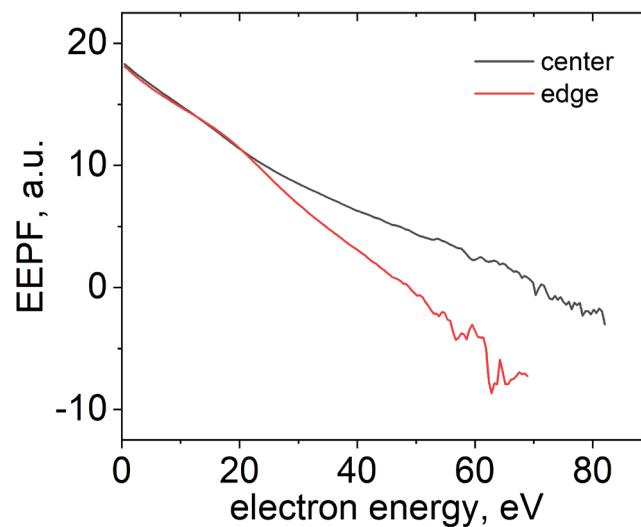
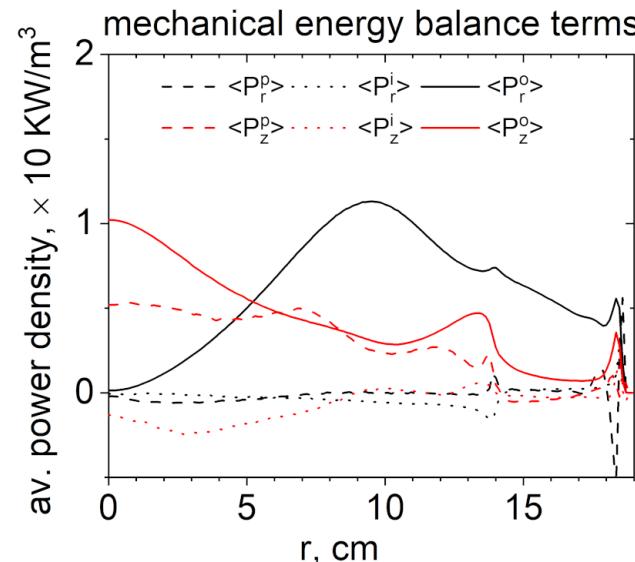
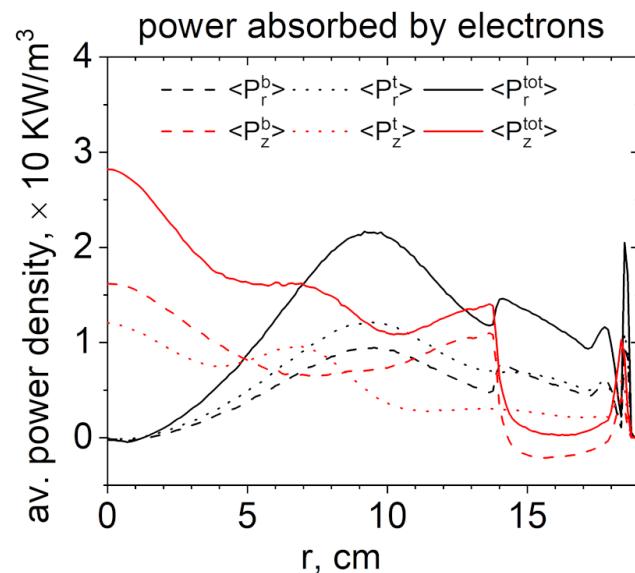
Energetic electron and ionization rate profiles



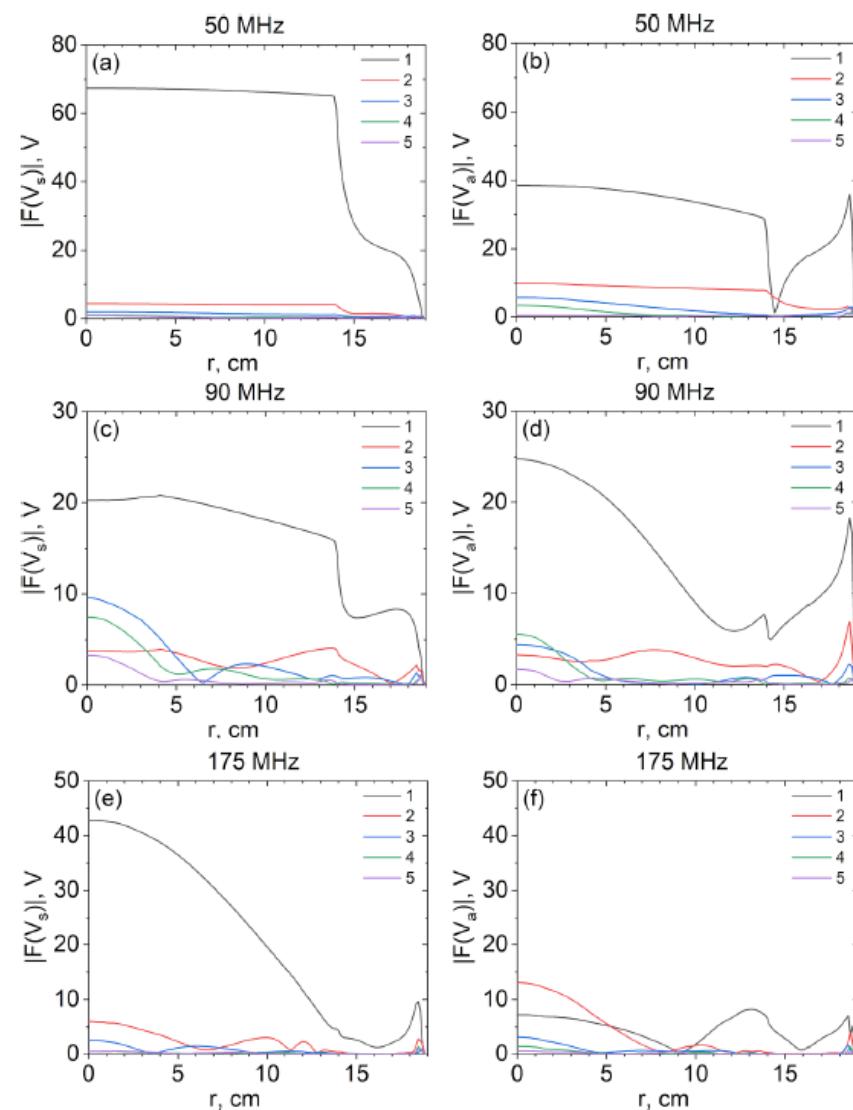
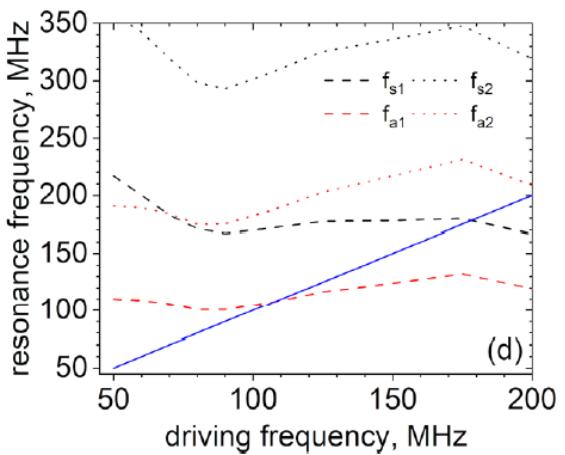
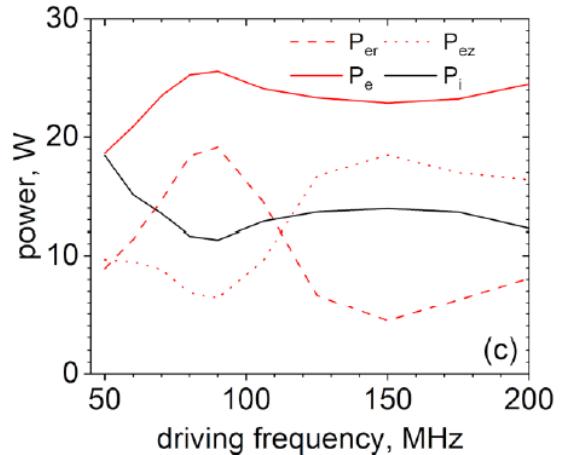
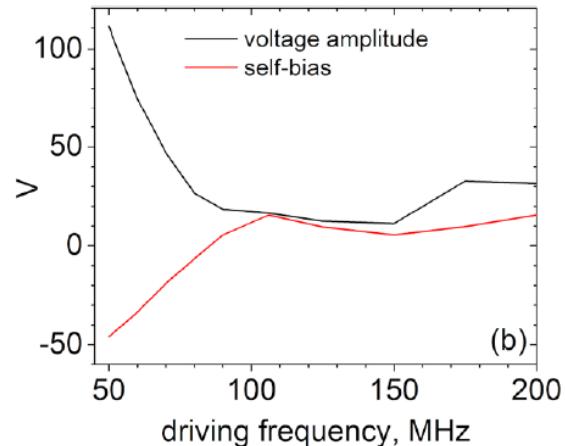
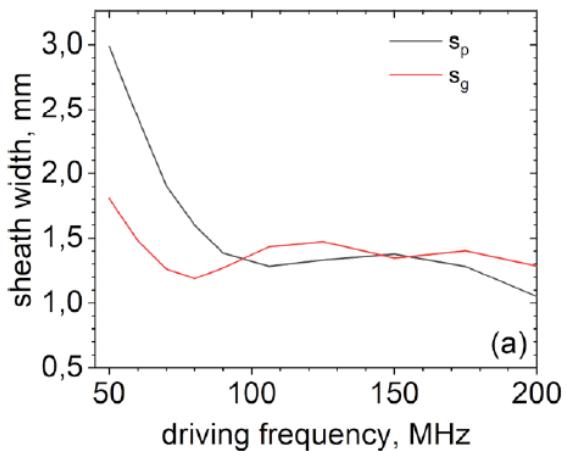
Electron Energization by Different Modes (cont.)



Mechanical Energy Balance Analysis



Driving Frequency Scan and Resonant Mode Excitation



Conclusions

- An energy- and charge-conserving implicit electromagnetic particle-in-cell/Monte Carlo code ECCOPIC2M is validated with VHF CCP experimental data for four cases with different gas pressure and absorbed power
- Comparison of the power absorption radial profiles between EM and ES simulations reveals that it alone does not govern the radial plasma density profile nonuniformity
- A more important parameter is the radially resolved EEDF, which reflects amount of energetic electrons above the ionization threshold, since the ionization profile determines the plasma density and ion flux radial profiles. It is shown that electrons are energized primarily due to interaction with (symmetric) surface modes at the sheath. The corresponding interaction is manifested through a significant “pressure heating” contribution in the mechanical energy balance. The antisymmetric modes heat electrons primarily via the inefficient Ohmic heating
- A driving frequency scan demonstrates that various surface mode resonances result in peaks on the total power absorption in the radial (for asymmetric modes) and the axial (for symmetric modes) direction

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